Electronic Supplementary Information

Pressure-Driven Multiple Optoelectronic Evolution in

CsMoO₃(IO₃) with Dual Functional [MoO₆] and [IO₃] Groups

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Figure S1. *Lebail* refinement of CsMoO₃(IO₃) at ambient condition with the space group of *Pna*2₁, cell parameters a = 7.9055 Å, b = 10.4477 Å, c = 7.4009 Å.



Figure S2. Lebail refinement of CsMoO₃(IO₃) at 0.7 GPa, and 14.9 GPa.



Figure S3. (a) The XRD patterns of the released sample and the sample at 0.7 GPa. (b) The Raman spectra the released sample and the sample at 0.6 GPa in the region of $600-1000 \text{ cm}^{-1}$.



Figure S4. Models of the [MoO₆] and [IO₃] groups obtained by geometry optimization at selective pressures.

Table S1.	The contribution	of dual functional	groups to the	optoelectronic p	operties.
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	Piezochromism	SHG	Enhancement of
	1 lezoemonnsm	transformation	photocurrent switching ratio
[MoO ₆] group		\checkmark	\checkmark
[IO ₃] group	×	\checkmark	\checkmark